



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No. : 10/040,042 Confirmation No.: 1835
Applicant : Wei-Yu Su
Filed : November 7, 2001
TC/A.U. : 1746

Title : Method for Reduction of Photomask Defects

Docket No. : N1085-90003
Customer No. : 08933

PETITION FOR EXTENSION
37 C.F.R. §1.136(a)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Applicant requests retroactive extension of the term for response to the official action mailed July 11, 2005 (Paper No. 20050612), to and including the filing of the accompanying Amendment and Response. The required fee for the requested one-month extension should be charged to Deposit Account No. 04-1679.

Respectfully submitted,

Date 10/14/05

Richard A. Paikoff
Richard A. Paikoff
Registration No. 34,892
Duane Morris LLP
30 South 17th Street
Philadelphia, PA 19103-4196
Telephone No.: 215-979-1853
Facsimile: 215-979-1020

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